

WEST Search History

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DATE: Thursday, July 08, 2004

Hide?	<u>Set</u> <u>Name</u>	<u>Query</u>	<u>Hit</u> <u>Coun</u>
	<i>DB=PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP=OR</i>		
<input type="checkbox"/>	L9	L8	4
<input type="checkbox"/>	L8	semiconductor and ((rinsing and drying) with wafer with cleaning)	4
<input type="checkbox"/>	L7	L5 and rins\$3 and dry\$3	
<input type="checkbox"/>	L6	L5 and risn\$3 and dry\$3	
<input type="checkbox"/>	L5	tungsten and polysilicon and (gate or bit) and nitride and (polymer with (stringer\$1 or residue\$1))	1
<input type="checkbox"/>	L4	tungsten and polysilicon and (gate or bit) and nitride and (polymer with (stringer\$1 or residue41))	
<input type="checkbox"/>	L3	L2 and (sulfuric same peroxide same HF)	
<input type="checkbox"/>	L2	(polymer same residue) and (clean\$3 and rins\$4 and dry\$4)	33
<input type="checkbox"/>	L1	(polymer same residue same RIE same tungsten)	

END OF SEARCH HISTORY